Optoelectronic and Birefringence Properties of Weakly Mg Doped ZnO Thin Films Prepared by Spray Pyrolysis

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Abstract

$\text{Mg}_x\text{Zn}_{1-x}\text{O}$ thin films were deposited on glass substrate with x varied between 0.01 and 0.05 by spray pyrolysis at a temperature of 450 °C. The structural investigation showed that all thin films had ZnO wurtzite structure with a preferred (002) orientation. The gap energy was calculated using Tauc's plot and it decreased over the Mg content by 0.07 eV. The charge carriers' density dropped by an order of 10^5 as Mg content increased whereas the resistivity and the mobility increased. SEM observations revealed a significant difference between undoped and doped thin films. A 632.8 nm laser source prism coupler revealed 2 optical modes for every thin film in each Transverse Electric and Transverse Magnetic mode, the birefringence of the Mg doped films was positive. Both ordinary and extraordinary refractive indexes were found to decrease as the Mg content increased. Great attention has been paid to the relation between the refractive, charge carriers density and the optical band gap.

1 Introduction

Zinc Oxide (ZnO) is a multipurpose semiconductor with many uses such as ultra-capacitor electrode [1], spintronic devices [2], multigas and vapors sensing [3–7], piezoelectric devices [8], ultra-violet LEDs [9], UV detector [10, 11], transistor [12] as well as waveguides [13–15]. In its thin film form, ZnO has a large adaptation to several deposition methods such as chemical vapor deposition [16], pulsed laser deposition [17], spray pyrolysis [18], dip-coating [19] and electrochemical deposition [20]. ZnO has very interesting characteristics for application in electronics and optoelectronics devices, especially its exciton binding energy of 60 meV at 300K, a wide direct band gap of 3.37 eV [21]. In addition to an ordinary and extraordinary refractive indexes of $n_e = 2.006$ and $n_o = 1.990$ respectively [22].

To modify its electrical properties, ZnO was doped with Group III elements such as Al, Ga and In which acted as donor dopants to reinforce its n -type electrical nature and group V elements such as N, P, As and Sb which acted as acceptor dopants which changed ZnO to be a p -type semiconductor [23]. Controlling the refractive index of ZnO thin films was achieved by several ways including thermal annealing [24] and doping with In [25], Te, N [26] and Mg [27]. However, the effect of dopants on the optical and electrical properties of ZnO is still not well understood.

Tailoring ZnO optical and electrical properties via dopants while maintaining high quality films especially using spray pyrolysis is very attractive to both scientists and technology developers as it offers a control over several experimental parameters, it is cheap, uncomplicated and environmentally friendly.

Wurtzite $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ alloy is very interesting due to the high solubility of Mg in the ZnO wurtzite

matrix (up to 30%) [28]. Moreover, it offers control over a range of optical and electrical properties of ZnO such as widening of the optical gap energy up to 0.85 eV [29], consequently, it can be used for multiple purposes such as a top layer in $\text{Mg}_x\text{Zn}_{1-x}\text{O}/\text{ZnO}$ multilayer UV photodetector [30] and high mobility MgZnO/ZnO thin film transistor [31] to name few. Concerning the waveguiding properties, little attention has been paid to wurtzite $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ as a waveguide, however, $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ was used as a buffer layer for ZnO waveguide thin film [32]. In another work, a potential use of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ cubic rocksalt-type phase as a wave guide was reported Yu et al. [33]. Wurtzite $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ thin film alloy refractive index was previously studied but there is still work to be done, as there are opposite results regarding the birefringence which is found to be negative in some studies [21, 34] and positive in another study [27].

In this work, we engaged in the investigation of the relations between the refractive index, the optical gap energy and the charge carriers' density in addition to the birefringence of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ thin films deposited by spray pyrolysis on glass substrate.

2 Experimental

The sprayed solution for the undoped ZnO thin films was prepared by dissolving the proper amount of dihydrate zinc acetate $[\text{Zn}(\text{CH}_3\text{CO}_2)_2 \cdot 2\text{H}_2\text{O}]$ in 99.98% pure methanol to obtain 0.1 M solution that was submitted to a constant stirring at 60 °C for 45 min on a magnetic stirrer. Concerning the sprayed solution of the Mg doped ZnO thin films, we maintained the same parameters with the use of magnesium chloride $[\text{Mg}(\text{CH}_3\text{CO}_2)_2 \cdot 4\text{H}_2\text{O}]$ as Mg precursor and each time the proper amount was added to 0.1 M methanol solutions of $\text{Zn}(\text{CH}_3\text{CO}_2)_2 \cdot 2\text{H}_2\text{O}$ to produce the following contents of zinc and magnesium: $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ with x equals 0.01, 0.03 and 0.05.

An ordinary glass substrate were ultra-sonically cleaned in a 1:1 mixture of acetone and ethanol for 15 min and left to dry in air. The films were deposited using spray pyrolysis system. The deposition temperature was 450 °C.

In order to characterize our thin films, multiple techniques were used: Philips PANalytical X'Pert Pro diffractometer with a wave length of 1.5406 Å, environmental scanning electron microscope Philips XL30 ESEM FEG and for the electrical properties Ecopia HMS-3000 hall effect measurement system, finally for the optical measurements, Metricon 2010/M Prism (rutile TiO_2 : $n_e=2.8639$ and $n_o=2.5822$ at 632,8 nm with an apical angle of 44,60 °) Coupler was used to couple 632.8 nm HeNe laser light into air/ $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ /glass waveguide and Shimadzu UV-3101PC Spectrophotometer.

3 Results And Discussion

XRD analysis

From Figure 1(a) we can see clearly that all films exhibit a crystalline hexagonal wurtzite structure (JCPDS card no. 00-036-1451) with the quasi-predominance of (002) peak indicating the preferential growth of undoped and Mg doped ZnO thin films through the c-axis direction. However, weak intensity peaks of other crystallographic directions were observed in the following positions 31.96°(100), 36.56°(101), 47.87°(102), 63.17°(103) and 72.85°(004). The peak (002) experienced a shift towards higher angles over Mg doping (Figure 1(b)) which was reported by a number of authors [35–37] and it is due to the difference in the ionic radius between Mg^{+2} (0.57 Å) and Zn^{+2} (0.60 Å) [38]. This difference is directly related to the compression strain on the main axes of the wurtzite structure a and

c. Previously, Chang et al. [39] reported also similar compression strain in their sputtered MgZnO

thin films which were interpreted by good substitution between Mg and Zn ions. The grain size can be calculated by Debye-Scherrer formula [35]:

$$(1) D = \frac{K\lambda}{\beta \cos(\theta)}$$

where λ is the wavelength of the incident X-ray, θ is the Bragg's angle, K is the shape factor (0.9 for gaussian fit) and β is the Full Width at Half Maxima (FWHM) of the peaks. The crystallite size, lattice parameters and strain axes are tabulated in table 1. It should be noted that there was no significant change in the average crystallite size (33.13 nm for $\text{Mg}_0\text{Zn}_1\text{O}$ film and an average of 33.03 nm for the $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films) and the minus sign of the strain values (ϵ_a and ϵ_c) approves the compression nature of the strain. To calculate lattice parameter c of the thin films we used the Bragg's law (with $n=1$) and the d spacing of wurtzite structure.

Table 1: The information obtained and calculated from the XRD spectra.

sample	2θ (degree)	d spacing (Å)	Crystallite size (nm)	a (Å)	α (Å)	ϵ_a (10^{-3})	ϵ_c (10^{-3})
Mg0.00Zn1.00O	34.75	2.580	33.13	3.2306	5.1592	-3.4241	-5.4746
Mg0.01Zn0.99O	34.77	2.455	31.26	3.2240	5.1560	-5.4601	-6.0915
Mg0.03Zn0.97O	34.77	2.456	31.30	3.2256	5.1560	-4.9665	-6.0915
Mg0.05Zn0.95O	34.78	2.577	35.83	3.2298	5.1547	-3.6709	-6.3421

UV-Vis measurements

The transmittance of the thin films was slightly enhanced on average with the introduction of Mg in the visible region (400-800 nm). The limit of the absorption zone was shifted to smaller wavelengths which renders the thin films to be more dielectric as Mg doping is increased, this effect is directly related to the blue shift of the optical band gap and it was approximated for each film using the Tauc's plot:

$$ah\nu = A(h\nu - E_g)^n \quad (2)$$

where $h\nu$ is the photon energy, E_g is the optical gap energy, A is constant and n equals $\frac{1}{2}$ since ZnO has a direct band gap.

The widening of the optical band gap could be ascribed to the difference in electronegativity between Zn^{+2} and Mg^{+2} ions [40–42]. In similar study, Al-Ghamdi [43] reported this correlation between the optical band gap energy and the electronegativity in his work about amorphous $Se_{96-x}Te_4Ag_x$ thin films.

In fact, it should be noted that both the electronegativity and electron affinity are directly related [44]. In this way Figure 4 presents the calculated optical band gap and the electron affinity versus Mg doping. The electron affinity ($e\chi$) was quantitatively calculated using Vegard's law [45]:

$$e\chi(Mg_xZn_{1-x}O) = e\chi(ZnO) - (e\chi(ZnO) - e\chi(MgO))x \quad (3)$$

$e\chi(ZnO)$, $e\chi(MgO)$ have the value of 4.5 eV [46] and 0.85 eV [47] for the electron affinity of ZnO and MgO respectively. Previously, iskenderoglu et al. [28] approved experimentally by UPS technique the inverse relation between the optical gap energy and the electron affinity of sprayed MgZnO alloy thin film, with Mg doping ranging from 0 to 15%.

Photoluminescence

The room temperature photoluminescence spectra are shown in Figure 5. The undoped thin film had four peaks at 381 (3.25 eV), 416 (2.98 eV), 441 (2.81 eV) and 505 nm (2.46 eV) which were explained by: the emission corresponding to excitons recombination, zinc interstitial (Zn_i), oxygen vacancies (V_O) and donor V_O – acceptor V_{Zn} recombination respectively [48, 49]. The same peaks were observed also in $Mg_{0.01}Zn_{0.99}O$ except a blue shift of the 380 peak to 381 nm (3.26 eV). The $Mg_{0.03}Zn_{0.97}O$ thin film had three peaks 379 (3.27 eV), 416 (2.81 eV) and 492 nm (2.52 eV) and they were attributed to excitons recombination, zinc interstitial (Zn_i) [48] and oxygen vacancy (V_O)

[50] respectively. Finally the $Mg_{0.05}Zn_{0.95}O$ thin film exhibited two peaks at 378 (3.28 eV) and 503

nm (2.47 eV) and they were manifestations of excitons and donor V_O – acceptor V_{Zn} recombinations [48, 49]. The blue shift of the near band edge emission from the PL peaks was in consistency with the UV visible calculations of the optical band gap, however, it was at a lower rate which was explained by stokes shift [51].

Electrical measurements

Figure 6 demonstrates the near isotropic electric transportation of the deposited films which could be attributed to the fact that the films have the predominant orientation (002) of the wurtzite structure [52].

The free charge carriers' density decreased from 3.146×10^{18} for the undoped film to $9.273 \times$

10^{13} cm^{-3} for $\text{Mg}_{0.05}\text{Zn}_{0.95}\text{O}$ film. In parallel, the resistivity increased from 109 to 1268 $\Omega \text{ cm}$ and the mobility increased from 0.01821 to 53.08 $\text{cm}^2/(\text{V.s})$. The decreased charge carriers' density could be attributed to the fact that the conduction band (CB) of pure ZnO consists mainly of O_{2p} and Zn_{4s} states [53, 54], so the introduction of Mg in ZnO thin films will reduce the Zn_{4s} state and introduce Mg_{3p} state which has high energy relative to the Zn_{4s} [55, 56]. Moreover, the widening in the optical band gap energy discussed previously, could also influence the free charge carriers' density since the electrons passing from the valance band must requires higher energy to access the conduction band.

Surface morphology

Figure 8 shows the morphology of undoped and 5 at. % doped ZnO thin films. The undoped (Figure 8(a)) thin film shows a dense surface with granular mixture of small grains and large aggregates. The size of the small grains varies from ~ 20 to 80 nm and that of the aggregates reaches ~ 200 -300 nm. From the doped sample (Figure 8(b)), it is evident that magnesium has a tendency to promote the phenomenon of coalescence. This doped film shows a less dense and relatively homogeneous morphology with large aggregates whose size varies from ~ 200 to 500 nm.

No cracks nor empty holes were observed on the surface of the films, revealing the high quality of our films.

M-lines measurements

The M-lines measurements demonstrated the guiding modes present in the films. All films had four guiding modes (TE_0 , TE_1 , TM_0 , and TM_1) two for each optical polarization (Transverse Electric mode (TE) and Transverse Magnetic mode (TM)) as illustrated in Figure 9. Using the dispersion equations for TE and TM polarizations, the optogeometric parameters can be calculated [57–59]. The effective indices, the films thicknesses and the birefringence values are presented in Table 2.

Figure 10 illustrate the variation of n_{TE} , n_{TM} , optical gap energy and free charge carriers' density as a function of the Mg concentration. The slight difference between n_{TM} and n_{TE} confirmed the birefringence behavior of our films. This made the guided waves traveling during the TE mode in the plane perpendicular to the c -axis of the wurtzite structure submit to an ordinary refractive index (n_{TE}) and during the TM mode to an extraordinary one (n_{TM}) [22]. Both n_{TE} and n_{TM} were found to decreased over Mg doping. This behavior seems to be in good agreement with the broadening of the optical band gap and the depletion of the conduction band free charge carriers' (Figure 10) [60]. The birefringence was measured to be positive for all films which is a good indication for the unchanging orientations of the bonds Zn-O with the replacement of Zn by Mg [61, 62].

Table 2: Optogeometric Properties of the deposited thin films.

Sample $\text{Mg}_x\text{Zn}_{1-x}\text{O}$	Effective index $\pm 10^{-4}$				Thickness TE	Thickness TM	Refractive index $\pm 10^{-4}$		Birefringence ($n_{\text{TE}}-n_{\text{TM}}$)
	TE_0	TE_1	TM_0	TM_1	± 0.1 (nm)	± 0.1 (nm)	nTE	nTM	
Mg0.00Zn1.00O	1.8923	1.6565	1.8793	1.6033	436.1	452.1	1.9699	1.9761	0.0062
Mg0.01Zn0.99O	1.8758	1.5994	1.8539	1.5486	347.4	382.6	1.9680	1.9682	0.0002
Mg0.03Zn0.97O	1.8738	1.6203	1.8581	1.5647	413.1	426.3	1.9580	1.9652	0.0072
Mg0.05Zn0.95O	1.8451	1.5981	1.8278	1.5494	417.7	433.7	1.9278	1.9314	0.0036

The inverse relation between the optical gap energy, the resistivity and the refractive index as Mg content increased in the ZnO thin film was also observed by Kaushal et al. [63]. The same fact has been reported by Teng et al. [27] for Mg-doped ZnO thin films prepared by pulsed laser deposition. In similar study, Sorar et al. [64] found that the ordinary refractive index generally decreases with the increase of the Si doping in ZnO thin films prepared by sol-gel and annealed at 350 °C and 550 °C whereas their optical band gap energy was found to be blue shifted.

4 Conclusion

Mg doped ZnO thin films were successfully deposited on glass substrate via spray pyrolysis at 450°C. The XRD characterization showed highly *c* oriented thin films with a decrease in *a* and *c* as the Mg concentration increased in the thin films. The undoped thin film had a multisize grain distribution meanwhile the $\text{Mg}_{0.05}\text{Zn}_{0.95}\text{O}$ had a more homogeneous grain distribution. Mg doping in the ZnO films led to a blue shift of the optical band gap energy and a depletion of the conduction band due to the drop in free carriers' density that had a direct effect on the ordinary and the extraordinary refractive indexes that were found to decrease. The birefringence of a crystal depends on multiple factors such as strain, defects charge carriers' density, bounds orientations and so on, therefore it will change from papers to papers with the change of deposition method especially.

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Figures

Figure 1

(a) XRD spectra of undoped and Mg doped ZnO thin films, (b) an emphasis of the (002) peak showing a shift towards higher angles for the doped thin films.

Figure 2

Transmittance spectra of pure and doped ZnO thin films zoomed in the absorption region.

Figure 3

Tauc's plot for the undoped and doped ZnO thin films.

Figure 4

The evolution of the optical band gap energy and the electron affinity of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ thin films as a function of Mg concentration.

Figure 5
(a) Room temperature photoluminescence spectra, (b) an emphasis of the excitons recombination peaks

Figure 6

I-V measurements for the four thin films: (a) undoped ZnO, (b) $\text{Mg}_{0.01}\text{Zn}_{0.99}\text{O}$, (c) $\text{Mg}_{0.03}\text{Zn}_{0.97}\text{O}$ and (d) $\text{Mg}_{0.05}\text{Zn}_{0.95}\text{O}$.

Figure 7

Resistivity (ρ) and charge carriers (n) as a function of Mg concentration.

Figure 8

(left) SEM images of the undoped ZnO thin film, (right) SEM images of the Zn_{0.95}Mg_{0.05}O thin films at 30k $\times$ and 50k $\times$, big and small picture respectively.

Figure 9

M-lines intensity vs angle of incident for the deposited doped and undoped films in both Transverse Electric (TE) and Transverse Magnetic (TM).

Figure 10

Ordinary (n_{TE}) and extraordinary (n_{TM}) refractive indices, optical gap energy and charge carriers' density as a function of Mg concentration.